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(54) **TOUCH SENSITIVE DEVICE WITH MULTILAYER ELECTRODE HAVING IMPROVED OPTICAL AND ELECTRICAL PERFORMANCE**

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(*) Notice: Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 892 days.

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G06F 3/041 (2006.01)

(52) **U.S. Cl.**
USPC **345/173**; 178/18.01; 178/18.03

(58) **Field of Classification Search**
None
See application file for complete search history.

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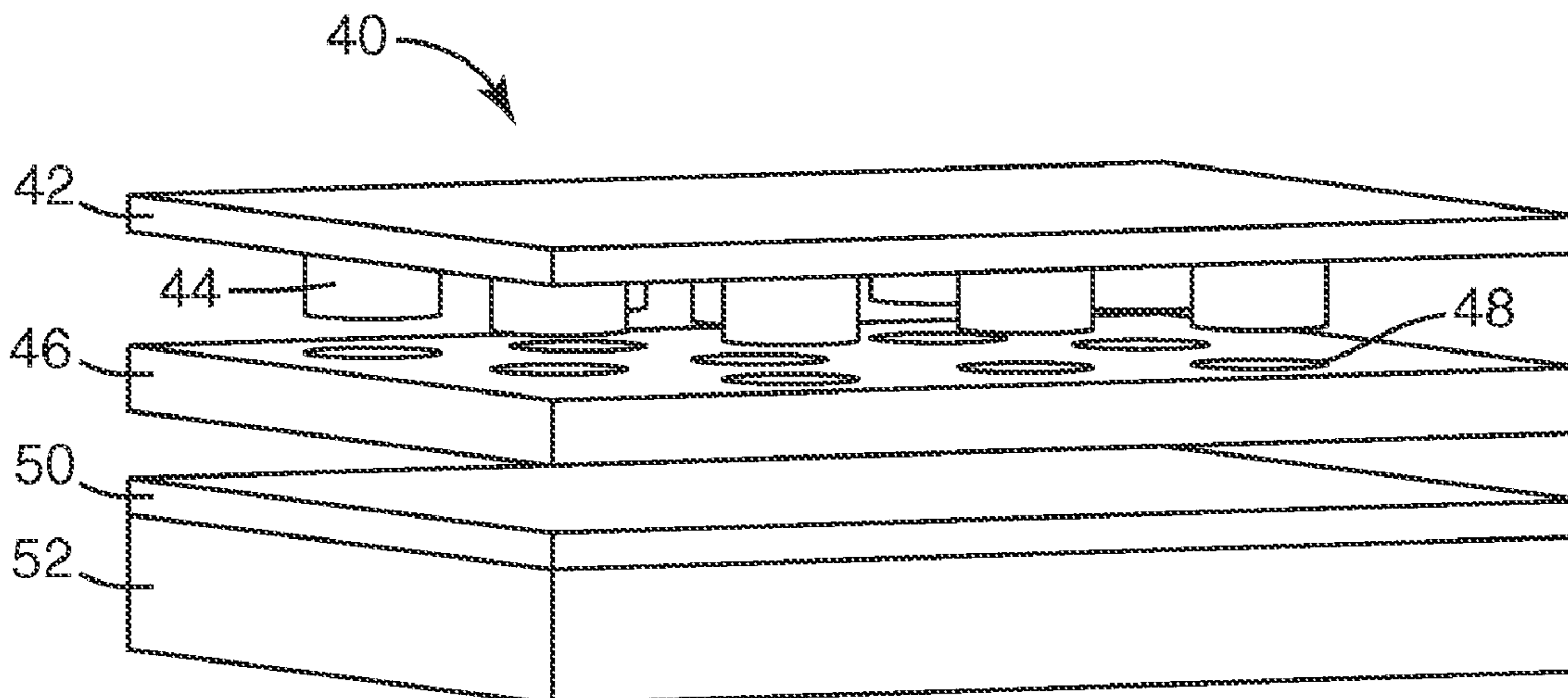
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(57) **ABSTRACT**

A touch sensor including one or more multilayer electrodes, said electrodes including at least two transparent or semi-transparent conductive layers separated by a transparent or semitransparent intervening layer. The intervening layer includes electrically conductive pathways between the first and second conductive layers to help reduce interfacial reflections occurring between particular layers in devices incorporating the conducting film or electrode.

16 Claims, 5 Drawing Sheets



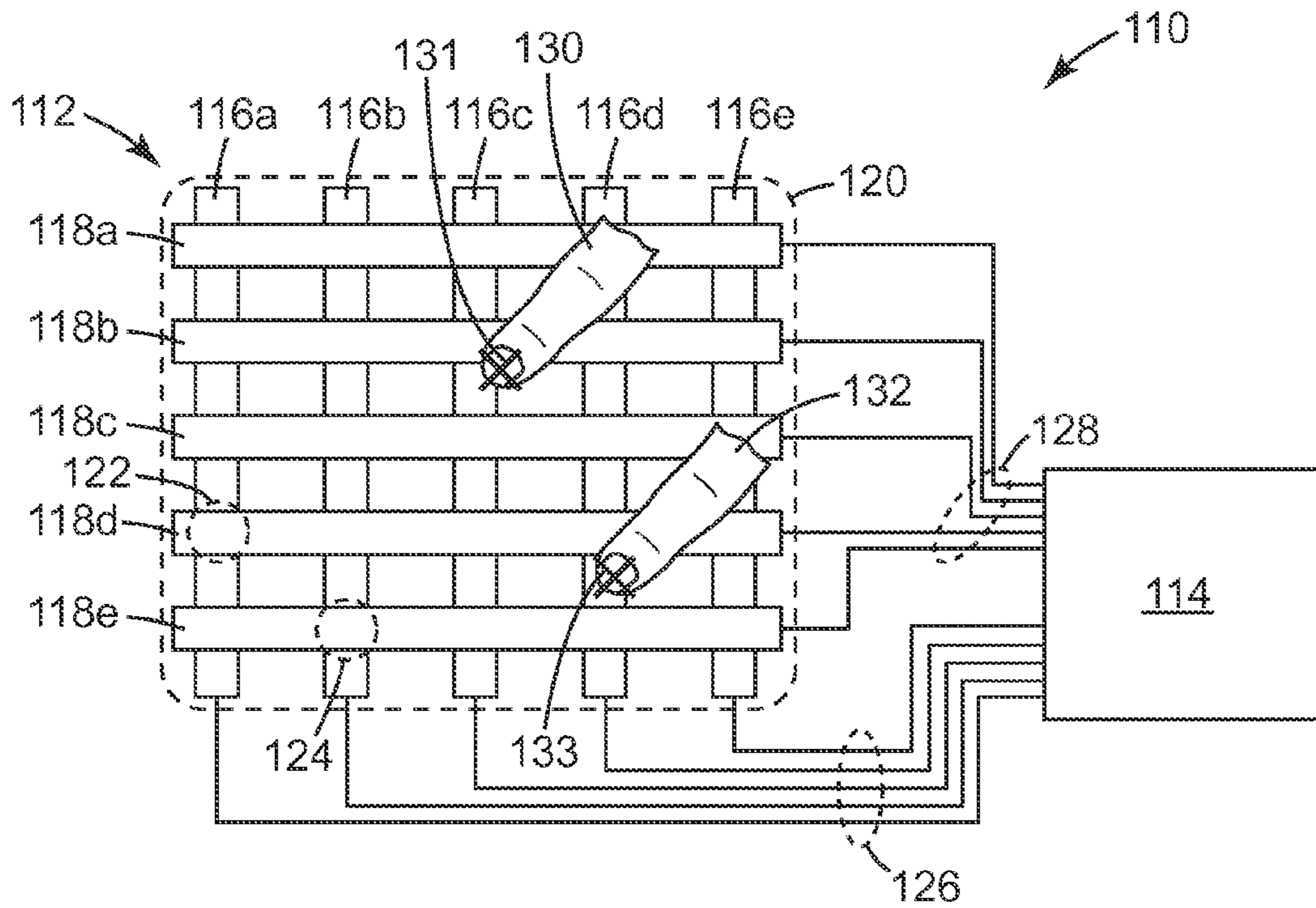


Fig. 1

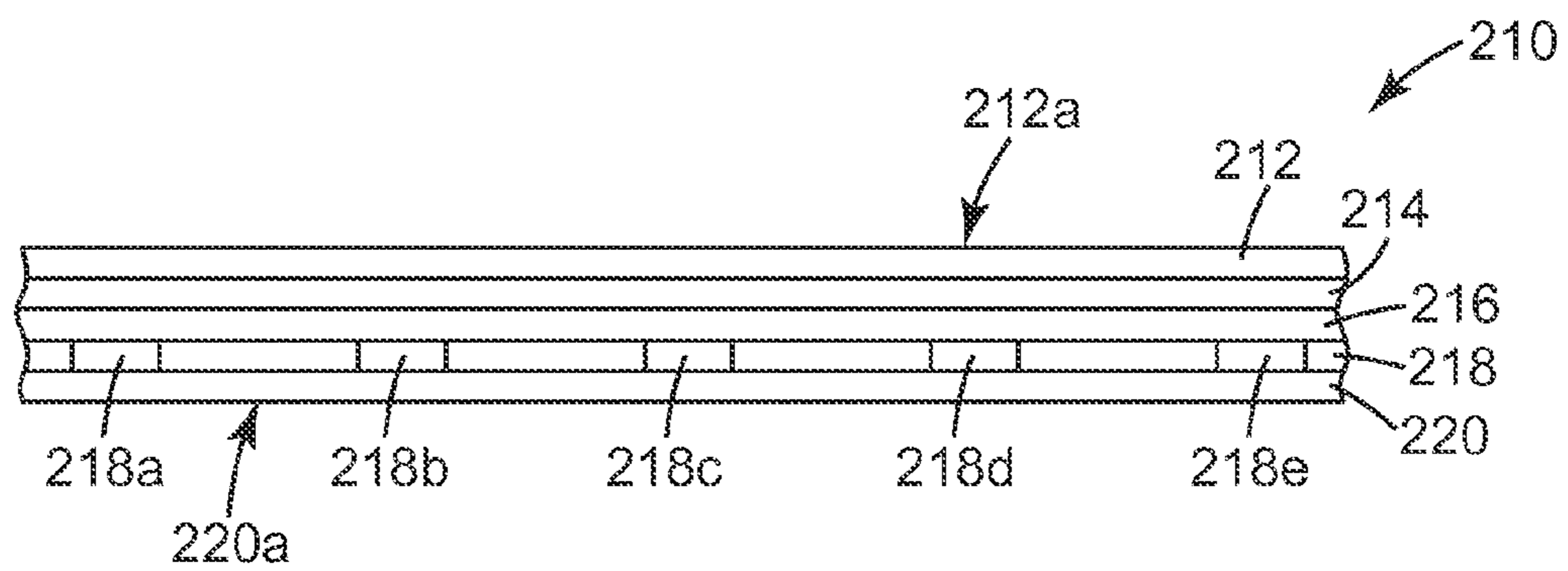


Fig. 2

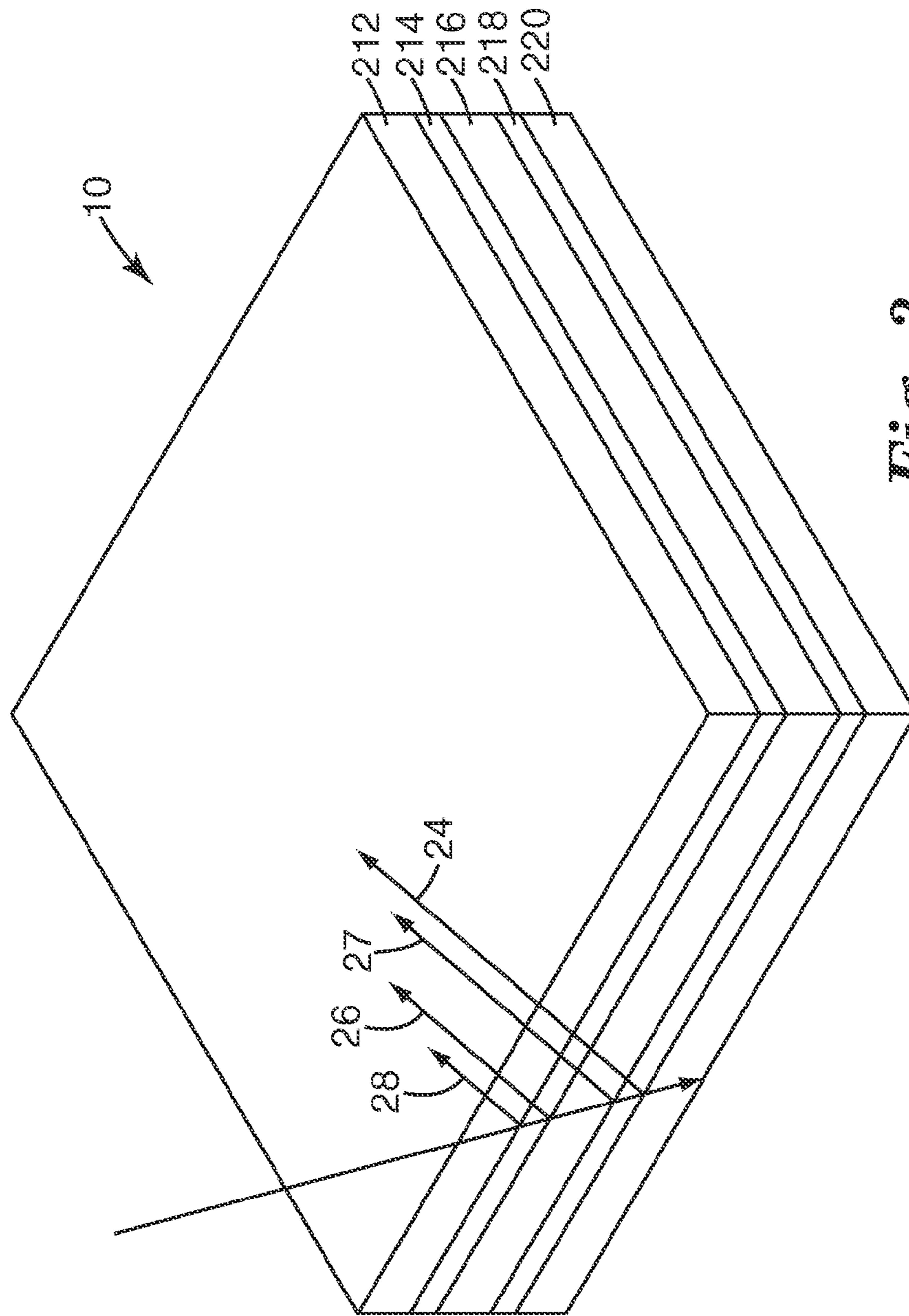


Fig. 3

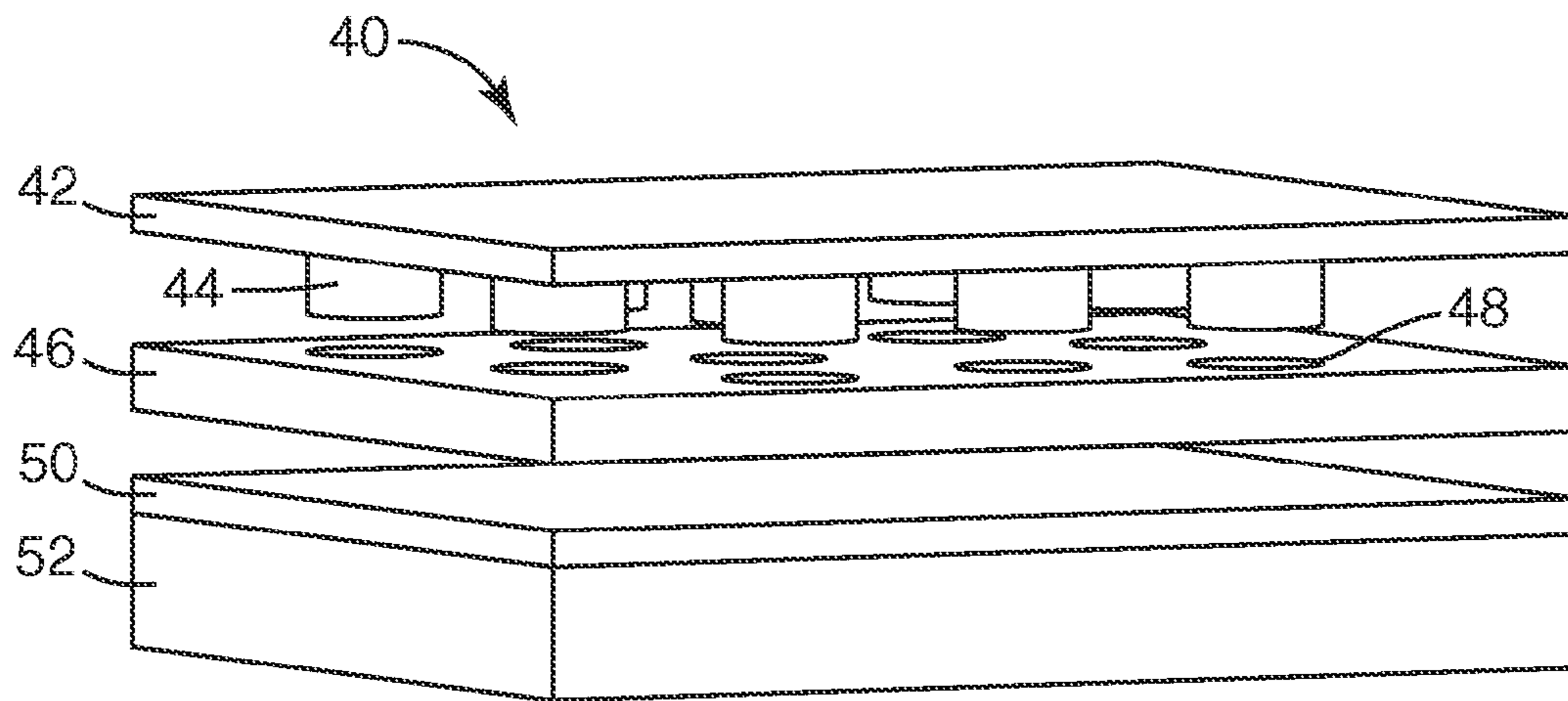


Fig. 4

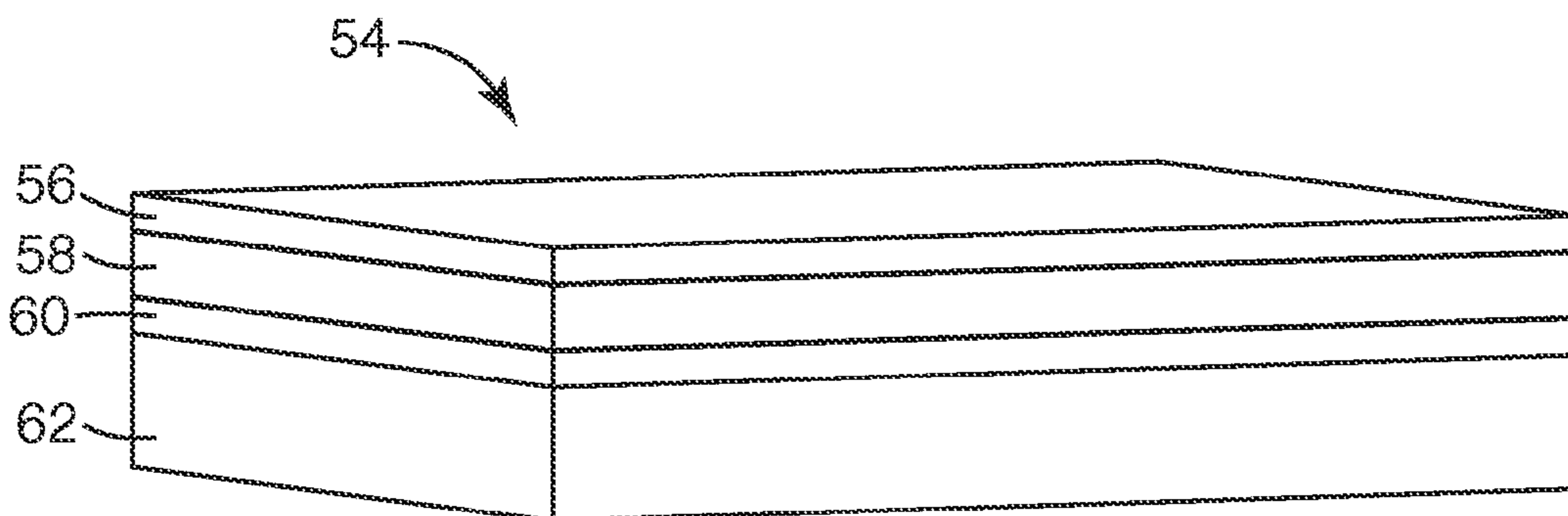


Fig. 5

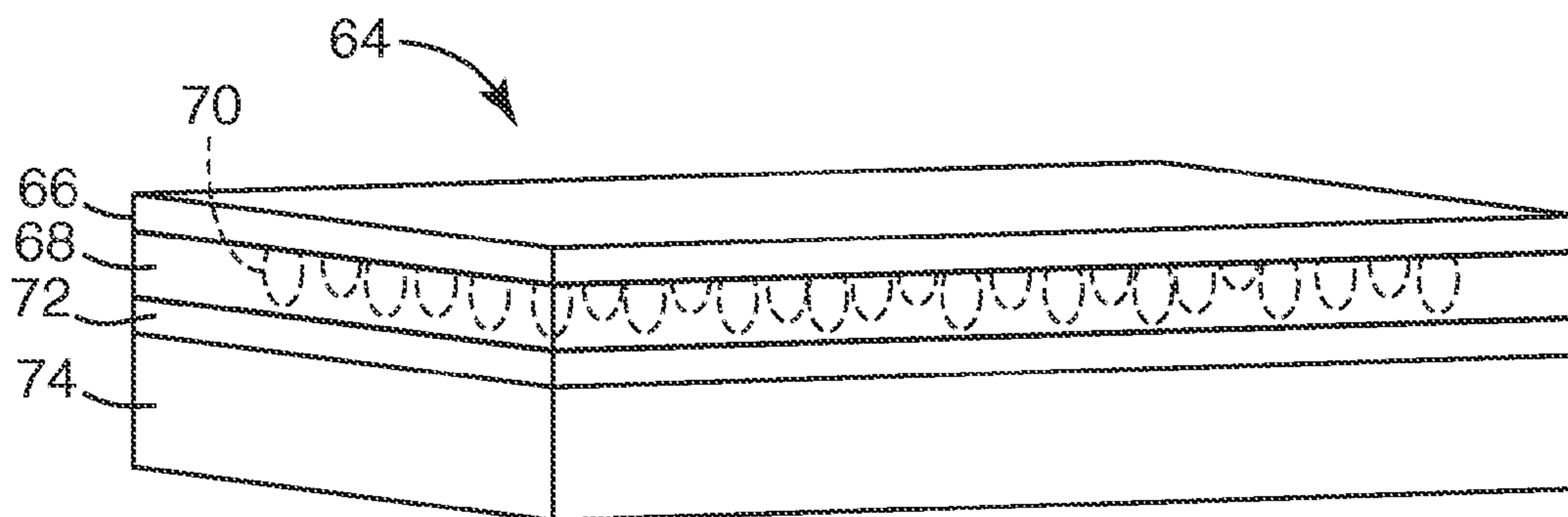


Fig. 6

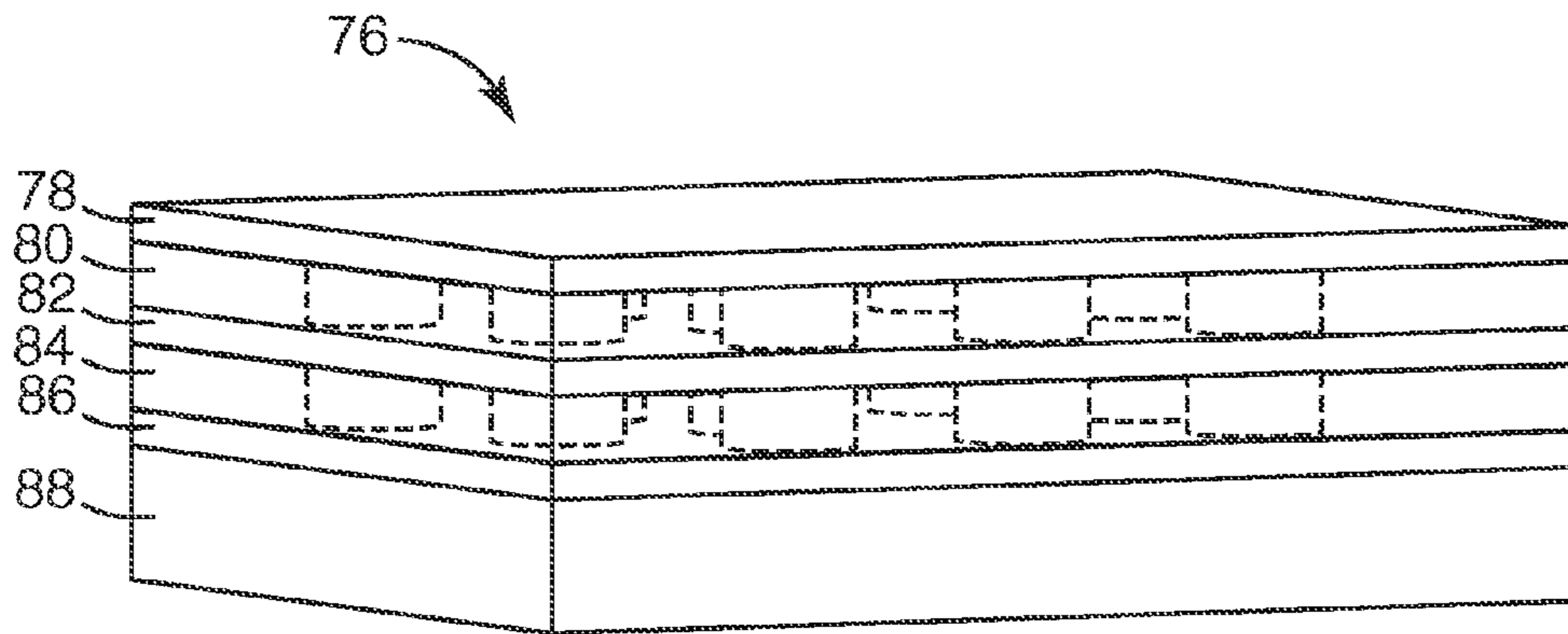


Fig. 7

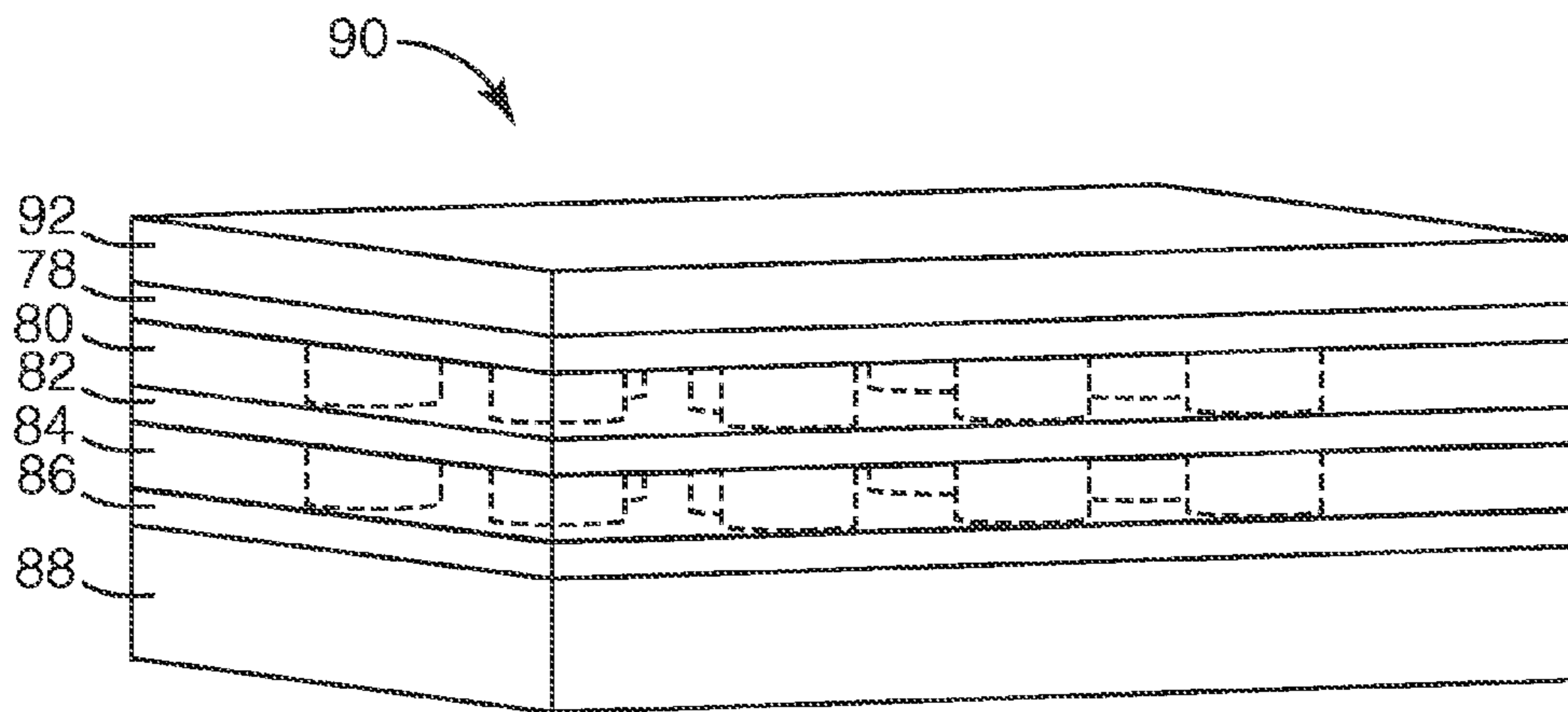


Fig. 8A

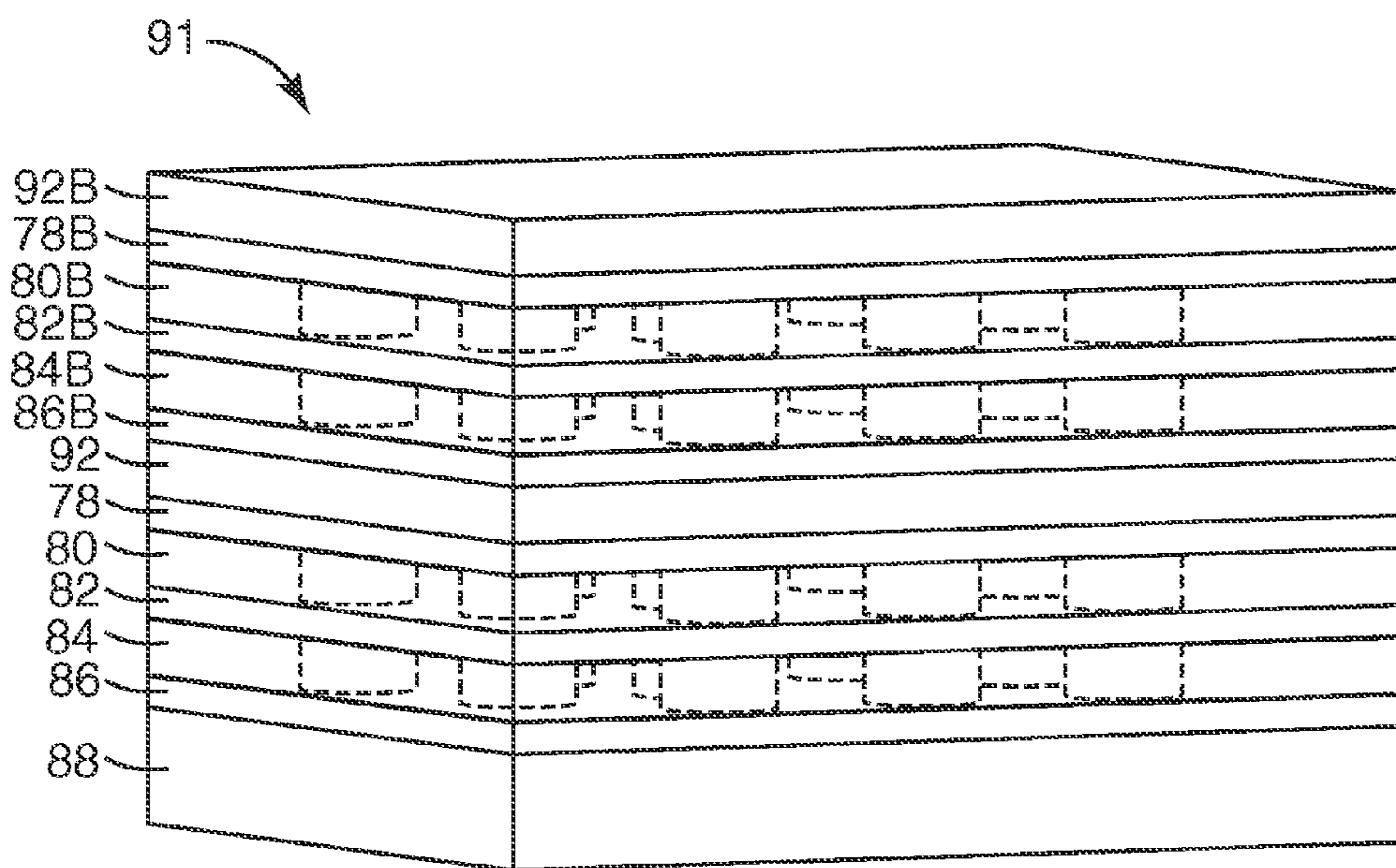


Fig. 8B

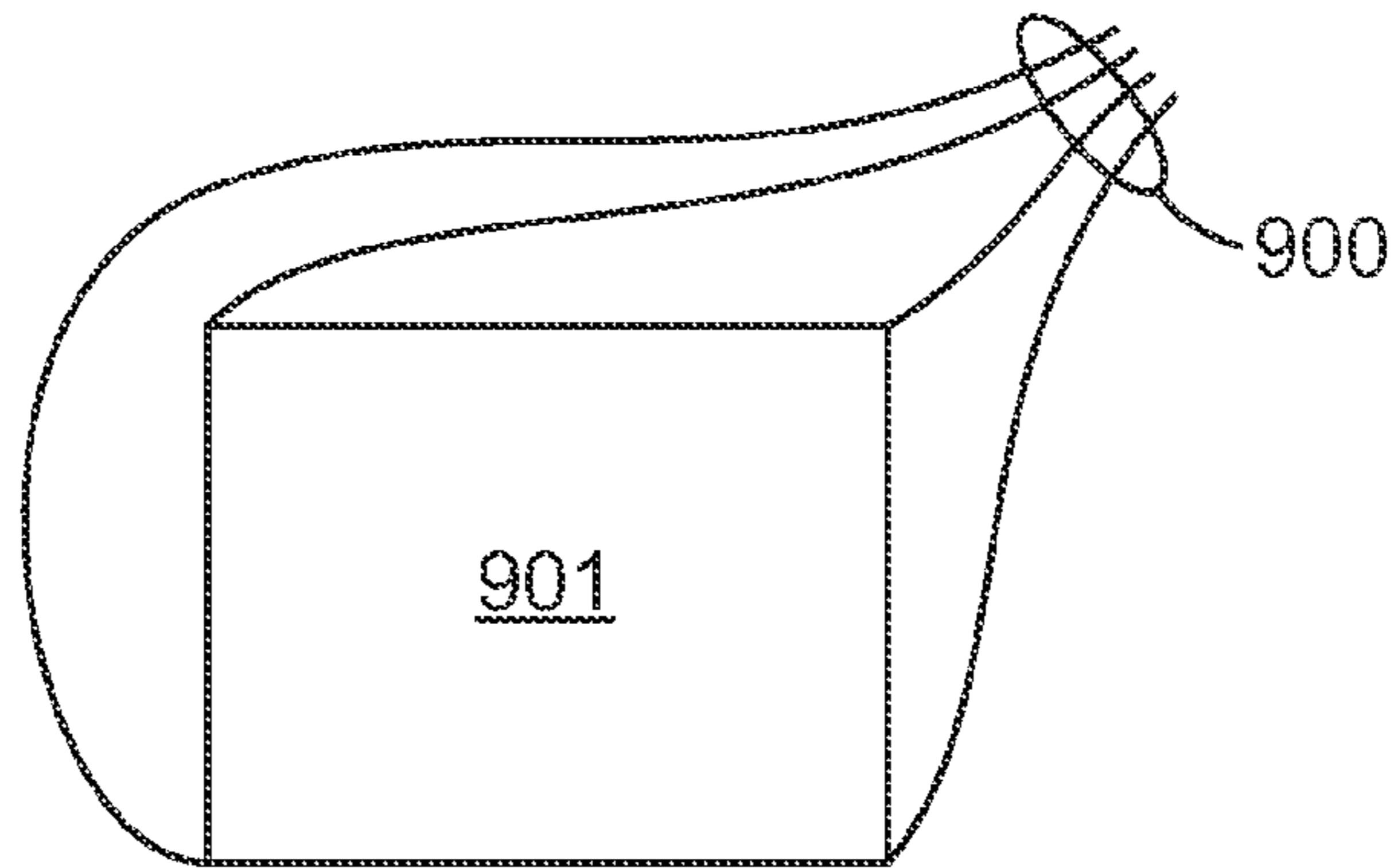


Fig. 9A

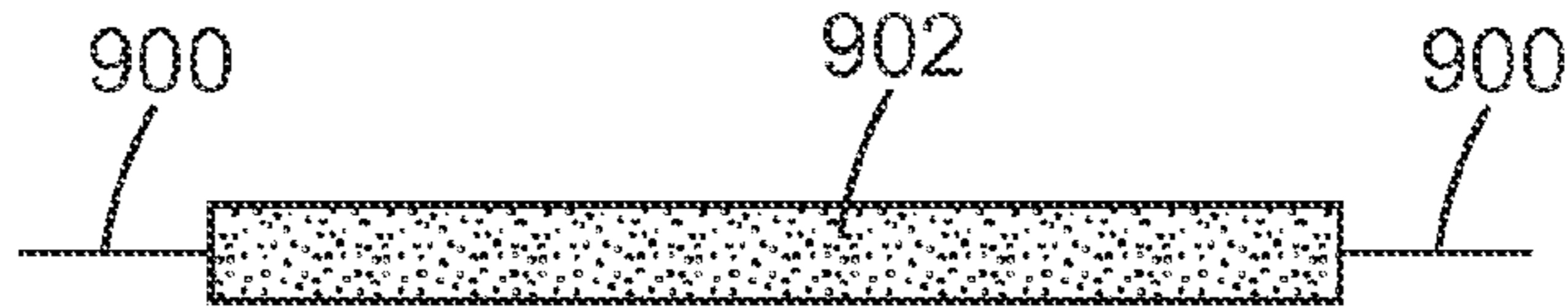


Fig. 9B

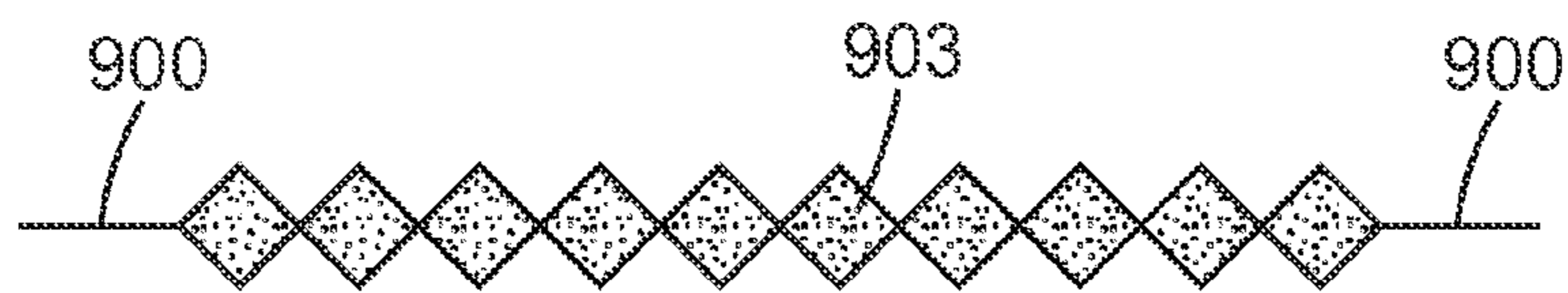


Fig. 9C

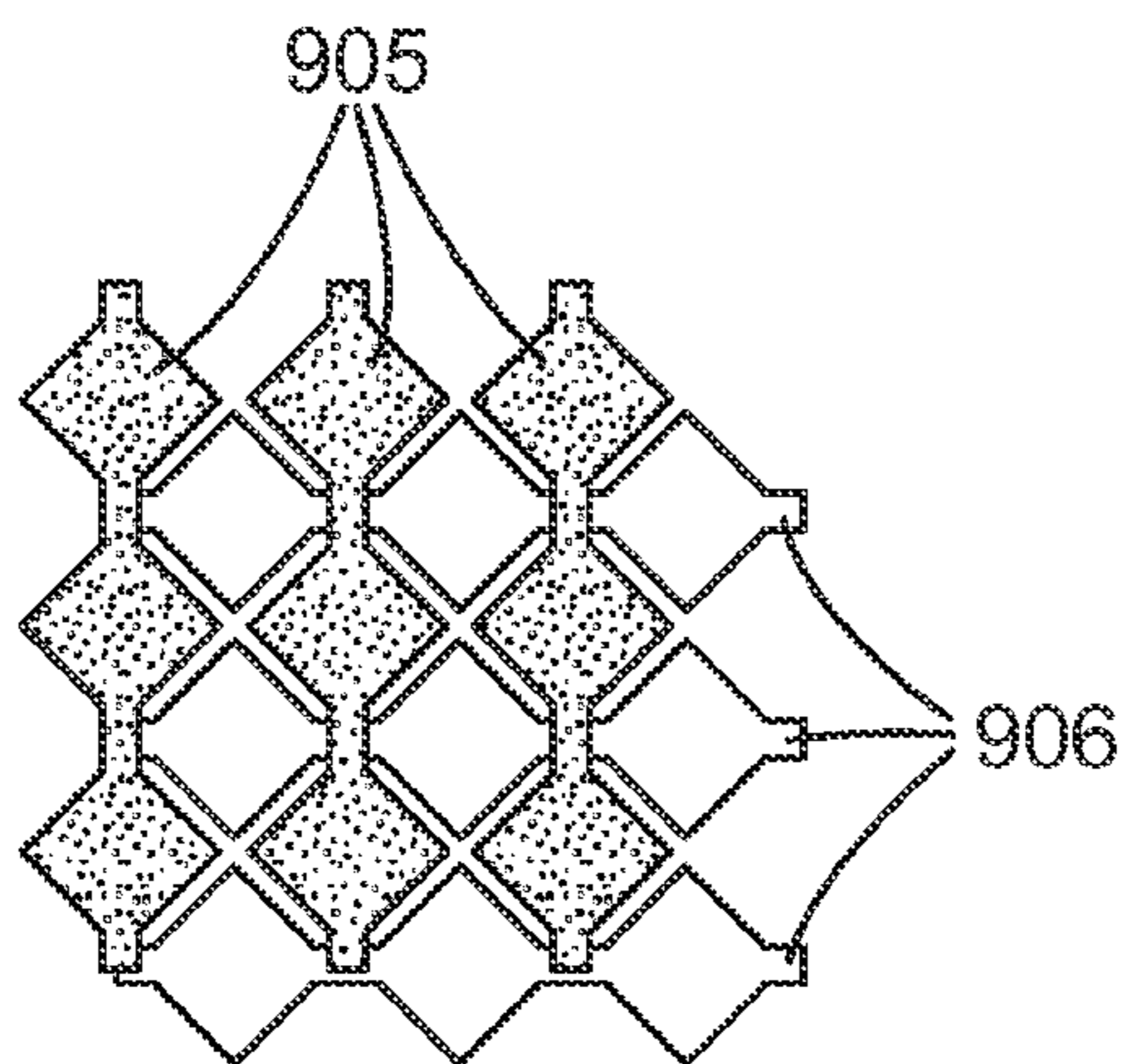


Fig. 10

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**TOUCH SENSITIVE DEVICE WITH
MULTILAYER ELECTRODE HAVING
IMPROVED OPTICAL AND ELECTRICAL
PERFORMANCE**

CROSS REFERENCE TO RELATED
APPLICATIONS

This application is related to U.S. patent application Ser. No. 12/540,394, "Conducting Film or Electrode with Improved Optical and Electrical Performance for Display and Lighting Devices and Solar Cells," filed Aug. 13, 2009; and U.S. patent application Ser. No. 12/141,544, "Conducting Film or Electrode with Improved Optical and Electrical Performance," filed Jun. 18, 2008.

BACKGROUND

Touch screens offer a simple and intuitive way for users to interact with computing devices, often by signaling a command by touching a transparent touch sensor overlaid upon a display. Touch sensors are typically constructed of single-layer electrodes formed of a transparent conductive oxide.

SUMMARY

A touch sensor having one or more conducting multilayer electrodes, consistent with the present invention, includes a substrate and, for each multilayer electrode, two transparent or semitransparent conductive layers separated by a transparent or semitransparent intervening layer. The intervening layer, which helps reduce unwanted interfacial reflections occurring in a device incorporating this electrode, includes electrically conductive pathways between the two conductive layers. The intervening layer also improves the durability of the conductive layers under conditions of flexing and bending. Use of the intervening layer and the conductive pathways between the conductive layers allows for thinner individual conductive layers. The thinner individual conductive layers are more flexible than a single conductive layer of the same combined conductive layer thickness. Flexing a single thick conductive layer would cause cracking under conditions where the two thinner conductive layers would survive intact. The conductive pathways between the two conductive layers also provide redundant electrical pathways such that cracking in one conductive layer will not lead to overall loss of conductivity. In a single thick conductive layer, cracking can lead to open circuits and premature device failure. The intervening layers may be chosen to optimize the overall flexibility of the conducting film.

BRIEF DESCRIPTION OF THE DRAWINGS

The accompanying drawings are incorporated in and constitute a part of this specification and, together with the description, explain the advantages and principles of the invention. In the drawings,

FIG. 1 shows a schematic view of a touch sensitive device and electronics;

FIG. 2 shows a cross section of a portion of a touch panel used in an exemplary touch sensitive device;

FIG. 3 shows a cross section of a portion of a touch panel used in an exemplary touch sensitive device;

FIG. 4 is a diagram of a multilayer electrode having an intervening layer with conductive paths;

FIG. 5 is a diagram of a multilayer electrode having an intervening conductive layer;

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FIG. 6 is a diagram of a multilayer electrode having an intervening layer with conductive particles dispersed in a binder;

FIG. 7 is a diagram of a multilayer electrode having multiple intervening layers;

FIG. 8A is a diagram of a multilayer electrode having multiple intervening layers;

FIG. 8B is a diagram of a cross-section of a matrix-type touch screen at a node, showing an X-axis multilayer electrode having multiple intervening layers, and a Y-axis multilayer electrode having multiple intervening layers;

FIG. 9A-C show various patterns the which the multilayer electrodes may be embodied; and,

FIG. 10 shows a plan view of a multilayer electrode pattern for a matrix-type touch screen prototype.

DETAILED DESCRIPTION

Embodiments of the present invention relate to touch sensors having multilayer electrodes with improved electrical and optical properties. The electrodes can be used within any sensor or display where, for example, reflections resulting between layers are detrimental to device performance. The sensors may be disposed on any suitable substrate, such as glass or PET. The multilayer electrodes may also be incorporated into non-transparent touch sensors. The multilayer electrode patterns may embody bars, triangles, honeycombs, or any other suitable pattern. The sensors may be coupled to electronic components that detect changes in inter-electrode, or electrode-to ground capacitance, and thereby determine the coordinates of a touch or near touch.

The multilayer electrodes include two or more conductive layers having a particular refractive index with intervening conductive or insulating layers having a different refractive index and having electrically conductive pathways. The conductive layers and intervening layers are each transparent or semitransparent. The thicknesses of the individual layers and the optical indexes of refraction of the individual layers within the electrode stack are tuned to minimize unwanted Fresnel reflections when these substrates are incorporated within touch sensor. In one embodiment, the conductive layers of the multilayer electrode are symmetric, meaning they have the same thickness. In other embodiments, the conductive layers can have different thicknesses.

This multilayer electrode construction significantly improves the black level, color saturation, and hence the contrast of the display. In addition, the intervening layers permit electrical contact between the conductive layers of the electrode. As a result, the electrical conductivity of the multilayer electrode is higher than that of the individual conductive layers within the stack. Since the size of the touch sensor may be limited by the sheet resistance of the electrodes, the multilayer electrode enables the fabrication of larger touch sensors. Sensors fabricated using the multilayer electrodes exhibit significantly improved electrical and optical performance compared with devices having single layer electrodes.

In FIG. 1, an exemplary touch device 110 is shown. The device 110 includes a touch panel 112 connected to electronic circuitry, which for simplicity is grouped together into a single schematic box labeled 114 and referred to collectively as a controller. The touch panel 112 is shown for simplicity as having a 5x5 matrix of column electrodes 116a-e and row electrodes 118a-e, but other numbers of electrodes and other matrix sizes can also be used, as well as other electrode patterns, including non-matrix type patterns such as single, non-patterned layers as are used in surface capacitive type touch sensors. Multilayer electrodes as described herein may,

in some embodiments enable very large capacitive-based multi-touch sensors, due to reduced resistance and increased signal to noise ratios.

The multilayer electrodes on panel **112** have a construction disclosed herein that yields improved electrical and optical properties. The panel **112** is typically substantially transparent so that the user is able to view an object, such as the pixelated display of a computer, television, hand-held device, mobile phone, or other peripheral device, through the panel **112**. The boundary **120** represents the viewing area of the panel **112** and also preferably the viewing area of such a display, if used. The multilayer electrodes **116a-e**, **118a-e** are spatially distributed, from a plan view perspective, over the viewing area **120**. For ease of illustration the multilayer electrodes are shown to be wide and obtrusive, but in practice they may be relatively narrow and inconspicuous to the user. Further, they may be designed to have variable widths, e.g., an increased width in the form of a diamond- or other-shaped pad in the vicinity of the nodes of the matrix in order to increase the inter-electrode fringe field and thereby increase the effect of a touch on the electrode-to-electrode capacitive coupling. From a depth perspective, the column electrodes may lie in a different plane than the row electrodes (from the perspective of FIG. **1**, the column multilayer electrodes **116a-e** lie underneath the row multilayer electrodes **118a-e**) such that no significant ohmic contact is made between column and row electrodes, and so that the only significant electrical coupling between a given column electrode and a given row electrode is capacitive coupling. The matrix of multilayer electrodes typically lies beneath a cover glass, plastic film, or the like, so that the electrodes are protected from direct physical contact with a user's finger or other touch-related implement. An exposed surface of such a cover glass, film, or the like may be referred to as a touch surface. Configurations of touch sensitive devices other than matrix are also possible using the multilayer electrodes described herein. For example, capacitive buttons comprising two electrodes disposed on a surface to come sufficiently close to one another within the area of the button to have capacitive coupling. These two electrodes (one or both being multilayer electrodes) may be on the same plane, formed in the same layer as one another. Also, rather than the matrix (comprised of a plurality of electrodes), other configurations such as a single sheet-type electrode are also possible. Such sheet-type electrodes are sometimes used in surface capacitive type sensors, and the electrode is an un-patterned coating that substantially covers the entire touch surface. Generally speaking, most known electrode configurations are possible using the multilayer electrodes described herein.

In exemplary embodiments some or all of multilayer electrodes (**116a-e**, **118a-e**) may be composed of two or more conductive layers having a particular refractive index and an intervening conductive layer having a different refractive index and having electrically conductive pathways.

The capacitive coupling between a given row and column electrode is primarily a function of the geometry of the electrodes in the region where the electrodes are closest together. Such regions correspond to the "nodes" of the electrode matrix, some of which are labeled in FIG. **1**. For example, capacitive coupling between column multilayer electrode **116a** and row multilayer electrode **118d** occurs primarily at node **122**, and capacitive coupling between column multilayer electrode **116b** and row multilayer electrode **118e** occurs primarily at node **124**. The 5x5 matrix of FIG. **1** has 25 such nodes, any one of which can be addressed by controller **114** via appropriate selection of one of the control lines **126**, which individually couple the respective column multilayer

electrodes **116a-e** to the controller, and appropriate selection of one of the control lines **128**, which individually couple the respective row multilayer electrodes **118a-e** to the controller.

In a mutual capacitance-type system, when a finger **130** of a user or other touch implement comes into contact or near-contact with the touch surface of the device **110**, as shown at touch location **131**, the finger capacitively couples to the electrode matrix. The finger draws charge from the matrix, particularly from those electrodes lying closest to the touch location, and in doing so it changes the coupling capacitance between the electrodes corresponding to the nearest node(s). For example, the touch at touch location **131** lies nearest the node corresponding to multilayer electrodes **116c/118b**. Preferably, the controller is configured to rapidly detect the change in capacitance, if any, of all of the nodes of the matrix, and is capable of analyzing the magnitudes of capacitance changes for neighboring nodes so as to accurately determine a touch location lying between nodes by interpolation. Furthermore, the controller **114** advantageously is designed to detect multiple distinct touches applied to different portions of the touch device at the same time, or at overlapping times. Thus, for example, if another finger **132** touches the touch surface of the device **110** at touch location **133** simultaneously with the touch of finger **130**, or if the respective touches at least temporally overlap, the controller is preferably capable of detecting the positions **131**, **133** of both such touches and providing such locations on a touch output **114a**.

Many possible drive and detection routines are possible and known in the art. A capacitance-to-ground type system measures changes in capacitance to ground occurring near nodes of the electrode matrix, rather than capacitance between electrodes.

Turning now to FIG. **2**, we see there a schematic side view of a portion of a multilayer touch sensor **210** for use in a touch device, such as device **110** of FIG. **1**. Touch sensor **210** includes upper layer **212** (which would be the layer closest to the user, and the upper surface **212a** of which would define the touch area of a touch sensor), which could be glass, PET, or a durable coating. Upper electrode layer **214** comprises a first set of multilayer electrodes. Dielectric layer **216** separates upper electrode layer from lower electrode layer **218**, which also comprises a set of multilayer electrodes **218a-e**, which in one embodiment are orthogonal to the first set of electrodes. In other embodiments, the upper and lower electrodes are not orthogonal to one another. Lower layer **220** may, like the upper layer, be glass, PET, or other material. The exposed surface **212a** of upper layer **212**, or the exposed surface **220a** of lower layer **220**, may be or include the touch surface of the touch sensor **210**. This is a simplified view of the stack that makes up the touch sensor; more or fewer layers and other intervening layers are possible.

Turning now to FIG. **3**, we see sensor stack **10**, a schematic three dimensional view of a portion of a multilayer touch sensor **210** for use in a touch device, such as device **110** of FIG. **1**. The cross section of FIG. **3** corresponds to that which would be seen at, for example, node **122** or **124** of FIG. **1**, and includes upper layer **212**, electrode **214**, dielectric layer **216**, electrode **218**, and lower layer **220**. The light reflected by an electrode includes the planar reflection and unwanted Fresnel reflections at each layer interface due to refractive index mismatches, represented by reflections **24**, **26**, **27** and **28**. Fresnel reflections are typically broadband and hence degrade the color saturation of the display. Light reflected by an electrode includes scattering and the interfacial Fresnel reflections. These reflections degrade the black level of an underlying display and hence the contrast ratio. They also make the electrodes within the sensor more noticeable to a

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user especially when the display is off or set to a single color in a region greater than an electrode.

The magnitude of the Fresnel reflection depends on the ratio of refractive indices at the interface. At normal incidence it is determined by the following equation:

$$R = \left(\frac{n - 1}{n + 1} \right)^2;$$

$$n = \frac{n_2}{n_1}$$

where n is the relative index of the two media with refractive indices n_2 , n_1 . Fresnel reflections are strongest at interfaces with the highest relative index. The refractive indices of the various layers of sensor stack **10** shown in FIG. **3** are the following: $n=2.0$ for the electrodes and $n=1.65$ for the substrate. In the sensor stack **10**, the highest index step thus occurs at the interfaces between the high index indium tin oxide (ITO) and the polyethylene terephthalate (PET) substrate. Sensor stack **10** includes two ITO/PET interfaces. Depending on the illumination these interfaces can reflect a significant portion of the incident light and make the electrodes quiet noticeable to the user.

In comparison, the multilayer electrode design of embodiments of the present invention yields both good optical and electrical performance. The intervening dielectric layer in the multilayer electrode design is a transparent or semitransparent layer having electrically conductive pathways that enable electrical contact between the two conductive layers. The pathways may form naturally by controlling the thickness and deposition conditions of the intervening layer. The chemical and physical properties of the first conductive layer nearest the substrate may also be adjusted to enable formation of these pathways by changing the wetting properties of the intervening layer such that the intervening layer is discontinuous to allow electrical contact between the adjacent layers. Alternatively, the pathways could be created using techniques such as laser ablation, ion bombardment or wet/dry etching.

The intervening layer may be deposited using vapor deposition techniques such as sputtering, e-beam, and thermal evaporation. The intervening layer can include polymers, including copolymers, such as polyacrylates, polymethacrylates, polyolefins, polyepoxides, polyethers, and the like, and inorganic materials such as metal oxides, nitrides, carbides, and mixtures thereof. Preferred non conductive intervening layers include polyacrylates and silicon oxides. The intervening layer may also be formed using solution coating. An ultrabARRIER film process, in which a monomer is evaporated onto the substrate and cured in-situ, may also be used. UltrabARRIER films include multilayer films made, for example, by vacuum deposition of two inorganic dielectric materials sequentially in a multitude of layers on a glass or other suitable substrate, or alternating layers of inorganic materials and organic polymers, as described in U.S. Pat. Nos. 5,440,446; 5,877,895; and 6,010,751, all of which are incorporated herein by reference as if fully set forth.

One embodiment is shown as a stack **40** of FIG. **4**. The multilayer electrode includes two high index conductive layers **42** and **50** of transparent conductive oxide (TCO) or semitransparent conductive oxide separated by a lower index transparent or semitransparent layer **46** having electrically conductive pathways comprising conductive links **44** extending through apertures **48** in transparent layer **46** to connect the

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electrodes **42** and **50**. A substrate **52** provides support for the electrode. The layers are drawn apart to illustrate the concept.

In another embodiment, the intervening layer is a transparent or semitransparent conductor with a lower refractive index than the conductive layers on either side, as shown in stack **54** of FIG. **5**. In the multilayer electrode included in stack **54**, the intervening conductive layer **58** may provide continuous electrically conductive pathways between the two adjacent conductive layers **56** and **60** of TCO or semitransparent conductive oxide. A substrate **62** provides support for the multilayer electrode. The intervening layer **58** may comprise a solution coated or electro-deposited conductive polymer. It can also be a vapor deposited transparent conductor. Conducting polymers include the following exemplary materials: polyaniline; polypyrrole; polythiophene; and PEDOT/PSS (poly(3,4-ethylenedioxythiophene)/polystyrenesulfonic acid). The combined thickness of the conductive layers is constrained by the sheet resistance requirements while the thicknesses of the individual layers are optimized for the desired optical properties.

In yet another embodiment, the intervening layer comprises conductive particles dispersed in a binder, as shown in stack **64** of FIG. **6**. The conductive particles **70** in binder **68** provide conductive pathways between the conductive layers **66** and **72** of TCO or semitransparent conductive oxide, thus forming the multilayer electrode. A substrate **74** provides support for the stack. The binder can be conductive or insulating. The conductive particles can be organic, inorganic, or metallic. Conductive particles also include metal coated particles. The refractive index of the intervening layer can be adjusted by varying the volume fractions of the binder and conductive particles.

The matrix and embedded conducting nanoparticles for the multilayer electrodes can include the following. The matrix can include any transparent or semitransparent (conductive or insulating) polymer (e.g., acrylates, methacrylates, or the conducting polymers listed above), or a transparent or semitransparent inorganic material either conductive (such as the TCOs listed above) or insulating (SiO_2 , silicon nitride (Si_xN_y), Zinc Oxide (Z_nO), aluminum oxide (Al_2O_3), or magnesium fluoride (MgF_2)). The conducting nanoparticles can include conducting polymers such as those listed above, metals (e.g., silver, gold, nickel, chrome), or metal coated particles. If the matrix is conductive then the nanoparticles can be insulating, in particular they can be nanoparticles of the insulating materials listed above (e.g., SiO_2 , silicon nitride, zinc oxide, or other insulating materials.)

Substrates for devices using the multilayer electrodes can include any type of substrate material for use in making a display or electronic device. The substrate can be rigid, for example by using glass or other materials. The substrate can also be curved or flexible, for example by using plastics or other materials. Substrates can be made using the following exemplary materials: glass; polyethylene terephthalate (PET); polyethylene naphthalate (PEN); polycarbonate (PC); polyetheretherketone (PEEK); polyethersulphone (PES); polyarylate (PAR); polyimide (PI); poly(methyl methacrylate) (PMMA); polycyclic olefin (PCO); cellulose triacetate (TAC); and polyurethane (PU).

Other suitable materials for the substrate include chlorotrifluoroethylene-vinylidene fluoride copolymer (CTFE/VDF), ethylene-chlorotrifluoroethylene copolymer (ECTFE), ethylene-tetrafluoroethylene copolymer (ETFE), fluorinated ethylene-propylene copolymer (FEP), polychlorotrifluoroethylene (PCTFE), perfluoroalkyl-tetrafluoroethylene copolymer (PFA), polytetrafluoroethylene (PTFE), polyvinylidene fluoride (PVDF), polyvinyl fluoride (PVF),

tetrafluoroethylene-hexafluoropropylene copolymer (TFE/HFP), tetrafluoroethylene-hexafluoropropylene-vinylidene fluoride terpolymer (THV), polychlorotrifluoroethylene (PCTFE), hexafluoropropylene-vinylidene fluoride copolymer (HFP/VDF), tetrafluoroethylene-propylene copolymer (TFE/P), and tetrafluoroethylene-perfluoromethylether copolymer (TFE/PFMe).

Other suitable substrates include barrier films and ultrabARRIER films. An example of a barrier film is described in U.S. Pat. No. 7,468,211, which is incorporated herein by reference as if fully set forth. UltrabARRIER films include multilayer films made, for example, by vacuum deposition of two inorganic dielectric materials sequentially in a multitude of layers on a glass or other suitable substrate, or alternating layers of inorganic materials and organic polymers, as described in U.S. Pat. Nos. 5,440,446; 5,877,895; and 6,010,751, all of which are incorporated herein by reference as if fully set forth.

TCOs for the multilayer electrodes include the following exemplary materials: ITO; tin oxides; cadmium oxides (CdSn_2O_4 , CdGa_2O_4 , CdIn_2O_4 , CdSb_2O_6 , CdGeO_4); indium oxides (In_2O_3 , Ga, GaInO_3 (Sn, Ge), $(\text{GaIn})_2\text{O}_3$); zinc oxides ($\text{ZnO}(\text{Al})$, $\text{ZnO}(\text{Ga})$, ZnSnO_3 , Zn_2SnO_4 , $\text{Zn}_2\text{In}_2\text{O}_5$, $\text{Zn}_3\text{In}_2\text{O}_6$); and magnesium oxides (MgIn_2O_4 , MgIn_2O_4 — $\text{Zn}_2\text{In}_2\text{O}_5$).

While the embodiments described above include two transparent or semitransparent conductive layers separated by an intervening layer, additional transparent or semitransparent conductive and intervening layers may be added depending on the desired optical and electrical properties, as shown in FIGS. 7 and 8A. Stacks 76 and 90 shown in FIGS. 7 and 8A include a substrate 88 and the following layers functioning as a single electrode: multiple transparent or semitransparent conductive layers 78, 82, and 86; intervening transparent or semitransparent layers 80 and 84 between the conductive layers. Additional layers of conductive layers and intervening layers can be added as well such that the electrode has any number of layers optimized or tuned for a particular device. It is also possible to incorporate the sensor onto the display stack, wherein the layer in contact with the display stack could be conductive or insulating as needed, as shown with respect to conductive layer 78 shown in FIG. 7 or an insulating layer 92 (such as an optically clear adhesive) shown in FIG. 8A. Furthermore, the multilayer electrode can be “tuned” to different optical properties for desired end uses. For example, the materials for the intervening layer, and the thicknesses of the layers, can be varied for a desired use or property, such as reducing reflection with a display is in the off state.

Whereas FIGS. 7 and 8A show a multilayer electrode having 3 conductive layers (and 2 intervening layers), FIG. 8B shows stack 91 from a cross section of a node on a matrix-type touch screen having X- and Y-electrodes, each electrode having a 3 conductive layer stack. Conductive layers 78, 82, and 86, in conjunction with intervening layers 80 and 84 comprise, for example, an X-axis electrode. Insulating layer 92, which could be a suitable optically clear adhesive, or a layer of PET, separates the X-axis electrode from the Y-axis electrode, which is comprised of conducting layers 78b, 82b, and 86b in conjunction with intervening layers 80b and 84b. While this construction is a 3 conductive layer per electrode, other arrangements are possible, such as 3 conductive layers for a given electrode, and greater than or less than 3 conductive layers for another electrode.

The multilayer electrodes can be used with other display devices such as electrophoretic devices (including use of Bridgestone’s powder), polymer dispersed liquid crystal (PDLC) devices, and inorganic electroluminescence (IEL)

displays and lighting devices. Examples of electrophoretic, PDLC, and IEL devices are described in, respectively, U.S. Pat. Nos. 7,365,900; 5,629,783, and 7,538,483, all of which are incorporated herein by reference as is fully set forth. Bridgestone’s powder is described in the publication entitled “Quick Response—Liquid Powder Display (QR-LPD)” from Bridgestone Corporation and is also described in U.S. Pat. No. 7,495,820, which is incorporated herein by reference as if fully set forth.

FIGS. 9a through 9c show various configurations of a multilayer electrode. FIG. 9a shows a sheet-type, unpatterned multilayer electrode 901, with wiring leads 900 connected to each corner. FIG. 9b shows a multilayer electrode 902 configured as a bar; FIG. 9c shows multilayer electrode 903 configured as repeating diamond shapes.

Example 1

Electrode substrates with the three-layer electrode design shown in FIG. 4 were fabricated with multiple parallel diamond-shaped electrodes, as shown in FIG. 9c. The three-layer electrode consisted of ITO(20 nm)/ SiAlO_x (42 nm)/ITO (20 nm), which were sputtered onto a roll of 0.005 inch (125 micrometer) thick PET.

The sheet resistance of these samples was measured to be approximately 123 ohms/square. The AC resistance measurements were measured according to the following procedure. The horizontal and vertical distances were measured on 10 sensor bars running horizontally and 10 running vertically, as shown in Table 1, below. Then a measurement was made for a rectangle of unpatterned ITO at the bottom of the vertical sensor sheet, as shown in Table 2, below. The measurements on the electrode substrates were taken using an Avant 600 ZIP from Optical Gaging Products Inc. of Rochester, N.Y., USA. The resistance measurements of the ITO bars and the ITO area were taken with a Fluke 77 Series II Multi-Meter (Fluke Corporation, Everett, Wash., USA.) To accurately measure the resistance of the ITO a piece of copper tape was connected to both ends. This piece of copper tape covered the entire width of the ITO area and provided a low resistance path to the higher resistance ITO. The resistance values were divided by the width, or average width in the case of the diamond pattern, to get the ohms/square. The 700 ohm measurement is a conservative measurement, due to the resistance of the z-axis adhesive connecting the copper tape, as well as to the small connection point of the probes.

TABLE 1

Bar	Horizontal Bar R (k Ω)	Vertical Bar R (k Ω)
1	29.77	31.47
2	29.89	29.68
3	29.83	28.32
4	29.84	27.3
5	29.71	26.59
6	29.68	25.89
7	29.7	25.05
8	29.58	24.75
9	29.43	24.49
10	29.59	23.68

TABLE 2

ITO Area Measurements	Horizontal	Vertical
Length (mm)	415.91	73.24

TABLE 2-continued

ITO Area Measurements	Horizontal	Vertical
Squares	5.68	
Resistance (Ω)	700	
Resistance/Square (Ω /sq)	123.27	

Touch sensors suitable for use over the front of a 19 inch diagonal computer monitor display were fabricated as follows: two sections of the electrode substrates were cut from the roll and laminated orthogonally, in registration, over each other on a glass substrate, using an optically clear adhesive (OCA), to form a matrix electrode sensor of the form shown in FIG. 10, which shows X-axis multi-layer electrodes **906** and Y-axis multi-layer electrodes **905**. The sensor construction layers were then as follows: glass (which typically served as the touching surface, farthest from the underlying display), OCA, PET electrode substrate, OCA, and crossed PET electrode substrate. Most of the electrical testing was done on prototypes having the ITO electrodes on the PET surface facing away from the glass, which required another layer of OCA and unmodified PET over the crossed electrode substrate to protect the outermost ITO electrodes. Having the ITO electrodes facing away from the glass allowed easier connection to the electrode layers for prototype testing.

The percent optical transmission of both our prototype sensor (having multi-layer electrodes) and a similarly designed vendor-supplied sensor (part number 98-0003-3367-8, available from 3M Touch Systems, Methuen, Mass., USA) were 90% (measurements ranged from 89.8 to 90.1% optical transmission (% T)). These were measured on BYK Gardner haze-gard plus machines (Catalog No. 4725, from BYK-Gardner USA, Columbia, Md., USA) which provide photopic measurements using white light, averaged over all visible wavelengths. Percent reflection (% R) was also measured. Results are in Table 3:

TABLE 3

Wavelength (nm)	Sensor		PET with Conductor	
	% R	% T	% R	% T
800	11.8	85.0	12.1	87.9
795	11.4	84.8	12.2	87.8
790	11.7	84.9	12.2	87.8
785	11.4	85.0	12.2	87.8
780	11.7	85.2	12.2	87.8
775	11.5	85.1	12.3	87.8
770	11.7	85.2	12.2	87.8
765	11.5	85.3	12.2	87.7
760	11.6	85.4	12.2	87.6
755	11.5	85.4	12.2	87.6
750	11.5	85.5	12.2	87.6
745	11.5	85.5	12.2	87.5
740	11.4	85.5	12.2	87.6
735	11.5	85.6	12.2	87.5
730	11.3	85.7	12.2	87.5
725	11.6	85.8	12.2	87.4
720	11.3	85.9	12.2	87.6
715	11.6	86.0	12.2	87.5
710	11.3	86.0	12.1	87.4
705	11.4	86.0	12.1	87.4
700	11.5	86.2	12.1	87.4
695	11.1	86.1	12.1	87.3
690	11.5	86.3	12.1	87.4
685	11.3	86.2	12.1	87.2
680	11.2	86.4	12.1	87.4
675	11.5	86.4	12.1	87.3
670	11.3	86.5	12.1	87.3
665	11.2	86.5	12.1	87.2

TABLE 3-continued

Wavelength (nm)	Sensor		PET with Conductor	
	% R	% T	% R	% T
660	11.4	86.6	12.1	87.3
655	11.3	86.6	12.1	87.2
650	11.2	86.6	12.0	87.3
645	11.3	86.7	12.0	87.3
640	11.4	86.7	12.0	87.3
635	11.3	86.8	12.0	87.3
630	11.2	86.7	12.0	87.3
625	11.3	86.8	12.0	87.3
620	11.4	86.8	11.9	87.2
615	11.4	86.9	11.9	87.3
610	11.3	86.8	11.9	87.3
605	11.2	86.8	11.9	87.2
600	11.3	86.9	11.8	87.4
595	11.4	87.0	11.8	87.3
590	11.5	87.0	11.7	87.3
585	11.5	87.0	11.7	87.4
580	11.4	87.1	11.6	87.4
575	11.4	87.0	11.6	87.4
570	11.3	87.0	11.5	87.5
565	11.3	87.0	11.5	87.5
560	11.3	87.0	11.4	87.4
555	11.3	87.0	11.4	87.5
550	11.4	87.1	11.3	87.7
545	11.4	87.1	11.2	87.7
540	11.4	87.1	11.1	87.8
535	11.4	87.1	11.0	87.8
530	11.4	87.0	10.9	87.8
525	11.5	86.9	10.8	87.9
520	11.5	86.9	10.7	87.8
515	11.4	86.9	10.6	87.9
510	11.3	86.7	10.5	87.9
505	11.3	86.7	10.4	88.0
500	11.4	86.7	10.3	88.0
495	11.4	86.6	10.2	88.1
490	11.4	86.6	10.1	88.3
485	11.4	86.6	10.1	88.4
480	11.5	86.7	10.0	88.5
475	11.5	86.4	9.9	88.4
470	11.4	86.2	9.8	88.2
465	11.5	85.9	9.7	88.0
460	11.4	85.6	9.7	87.9
455	11.5	85.4	9.7	87.8
450	11.5	85.1	9.7	87.8
445	11.6	84.8	9.8	87.5
440	11.6	84.6	9.9	87.2
435	11.7	84.1	10.0	86.6
430	11.8	83.6	10.3	86.0
425	11.9	82.9	10.5	85.3
420	12.0	82.3	10.9	84.4
415	12.1	81.5	11.4	83.2
410	12.3	80.6	11.9	81.8
405	12.4	79.4	12.6	80.1
400	12.6	77.7	13.5	77.9
395	12.8	75.8	14.5	75.6
390	13.0	73.8	15.6	73.0
385	13.2	71.2	17.0	70.1
380	13.5	68.5	18.5	66.9
375	13.8	65.7	20.2	63.3
370	14.4	61.7	22.3	59.1
365	15.1	56.2	24.6	54.5
360	16.0	51.0	27.3	50.2
355	17.3	47.3	31.4	46.3
350	21.2	43.4	40.3	42.6
345	28.3	40.0	56.5	39.4
340	34.0	36.7	71.4	36.5
335	34.5	31.9	78.4	33.1
330	32.4	24.7	79.9	28.7
325	28.2	15.7	80.4	22.6
320	21.4	6.9	81.3	12.7

The three layer electrode design enables low sheet resistance in conjunction with good optical performance. Each intervening low index layer permits electrical contact between the adjacent transparent conductive layers. As a

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result the conductivity of the multilayer electrode is determined by the combined thickness of all the conductive layers. The 19 inch diagonal touch sensor described above had essentially the same (~90%) transmission as the vendor-sourced ~400 ohm/square ITO electrodes, yet the example sensor had a sheet resistance of only ~125 ohm/square, which enabled excellent sensor signal uniformity.

The above sensor was tested by attaching the two orthogonal sets of electrodes to a touch sensor controller and signal processing electronics, as described in commonly-assigned and co-pending patent application U.S. Ser. No. 12/618,874, Touch Sensitive Device Using Threshold Voltage Signal, filed Nov. 16, 2009. The touch sensor was placed on a foam pad, with the glass side up. At least 10 simultaneous finger touches on the glass could be accurately located by the sensor and displayed by the associated electronics.

Example 2

A 19 inch (diagonal) touch sensor made of two orthogonal sets of multilayer ITO/SiAlO_x/ITO stacks was fabricated on PET film in the same process as used for Example 1. The sensor was tested by attaching the two orthogonal sets of electrodes to a touch sensor controller and signal processing electronics, as described in commonly-assigned and co-pending patent application U.S. 61/182,366, High-speed Multi-touch Touch Device and Controller Therefor, filed May 29, 2009. At least 10 simultaneous finger touches on the glass could be accurately located by the sensor and displayed by the associated electronics.

It was found that the prototype sensors can provide increased conductivity and improved signal-to-noise, while maintaining the same percent optical transmission, as indicated by the optical measurements in Example 1, above.

The invention claimed is:

1. A sensor for use in a touch sensitive device, the sensor comprising one or more electrodes disposed on a substrate, at least one or more of the electrodes comprising: a first transparent or semitransparent conductive layer; a second transparent or semitransparent conductive layer; and a transparent or semitransparent intervening layer located between the first and second conductive layers, the intervening layer including electrically conductive pathways between the first and second conductive layers, such that when the sensor is used in a touch sensitive device, each of the first transparent or semitransparent conductive layer, second transparent or semitransparent

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conductive layer, and transparent or semitransparent intervening layer, together, function as a single electrode.

2. The sensor of claim 1, wherein the first and second conductive layers each comprise a transparent or semitransparent conductive oxide.

3. The sensor of claim 1, wherein the one or more electrodes comprises a single, un-patterned electrode.

4. The sensor of claim 1, wherein the one or more electrodes comprises patterned electrodes disposed on the substrate to form a matrix.

5. The sensor of claim 1, wherein the one or more electrodes comprises a first and second electrode disposed on the same layer.

6. The sensor of claim 1, wherein the intervening layer comprises a dielectric polymer or an inorganic dielectric material.

7. The sensor of claim 1, wherein the intervening layer comprises a conductive layer having an index of refraction different from the indexes of refraction of the first and second conductive layers.

8. The sensor of claim 1, wherein the electrically conductive pathways comprise conductive links extending through apertures between the first and second conductive layers.

9. The sensor of claim 1, wherein the intervening layer comprises a binder and wherein the electrically conductive pathways comprise conductive particles suspended in the binder and extending between the first and second conductive layers.

10. The sensor of claim 1, wherein the thickness of the first conductive layer is substantially identical to a thickness of the second conductive layer.

11. The sensor of claim 1, wherein the substrate comprises polyethylene terephthalate.

12. The sensor of claim 11, further comprising an overlayment layer, the electrodes disposed between the substrate and the overlayment layer.

13. The sensor of claim 12, wherein the overlayment layer comprises polyethylene terephthalate or glass.

14. The sensor of claim 1, wherein the electrodes are disposed in a honeycomb pattern.

15. The sensor of claim 1, wherein the electrodes are disposed on the substrate to form an electrode matrix.

16. The sensor of claim 1, further comprising a display, and wherein the sensor is disposed upon the display such that elements appearing on a viewing screen of the display may be seen through the sensor.

* * * * *

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 8,730,184 B2
APPLICATION NO. : 12/639363
DATED : May 20, 2014
INVENTOR(S) : Manoj Nirmal

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

In the Specification

Column 6

Line 55, delete “naphthalate” and insert -- naphthalate --, therefor.

Line 66, delete “polytetrafluoroethyloene” and insert -- polytetrafluoroethylene --, therefor.

Column 7

Line 62, delete “then” and insert -- than --, therefor.

In the Claims

Column 12

Line 39, in Claim 14, delete “diposed” and insert -- disposed --, therefor.

Signed and Sealed this
Twenty-sixth Day of May, 2015



Michelle K. Lee
Director of the United States Patent and Trademark Office